



Call for Papers

March 4-8, 2018



ISPlasma2018 /IC-PLANTS2018

10th Anniversary International Symposium on Advanced Plasma Science and its Applications for Nitrides and Nanomaterials

11th International Conference on Plasma-Nano Technology & Science

Meijo University, Nagoya,
Japan



Venue:

Meijo University, New Dome-mae Campus

Plasma Science & Technologies

Plasma Source Advanced Plasma Diagnostics
Modeling & Simulation Plasma in Liquid
Thin Film Deposition Process Etching Process
Flexible Electronics Plasma Biology & Medicine
Plasma Agriculture Plasma for Nano & Green Technologies

Nanomaterials

Nanodots & Nanoparticles
Nanotubes, Nanowires & Nanorods
2D Nanomaterials Porous Materials & Membranes
Composites & Functionally Graded Materials
Surface Modification & Functionalization
Applications for Energy, Environment, Nanomedicine & Sensing

Nitride Semiconductors

Crystal Growth of GaN & Related Materials
MBE Growth & Nitrogen Source
Characterization Device Processing
Optical & Optoelectronic Devices
Electron & Power Devices

Biosensing

Detection Technologies
Optical Devices, Bioimaging
Electrochemical Devices Biosensors
Biomarkers & Biosensor Surfaces
Fabrication Technologies Biomaterials
Biodevices, μ TAS, Lab on a Chip

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<http://www.isplasma.jp/>

Organizing Committee

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